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Correction: Gate-tunable negative differential resistance in multifunctional van der Waals heterostructure

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In the original version of this Article, Saroj Prasad Dash and Samuel Lara-Avila were omitted as corresponding authors. Correspondence and requests for materials should also be addressed to saroj.dash@chalmers.se and samuel.lara@chalmers.se

Furthermore, an affiliation was omitted for Richa Mitra. Their correct affiliations are:

‘Department of Microtechnology and Nanoscience, Chalmers University of Technology, 412 96 Gothenburg, Sweden.’ and present address: ‘VTT Technical Research Centre of Finland Ltd, Espoo, Finland.’

The original Article has been corrected.

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